



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: **1752**

Serial Number: **10/629,806**

Examiner: **Sin J. Lee**

Filed: **July 30, 2003**

Confirmation No.: **9494**

For: **RESIST PATTERN THICKENING MATERIAL, PROCESS FOR
FORMING RESIST PATTERN, AND PROCESS FOR
MANUFACTURING SEMICONDUCTOR DEVICE**

Attorney Docket Number: **030923**
Customer Number: **38834**

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

September 29, 2005

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated April 29, 2005 for 2 months from July 29, 2005 to September 29, 2005.

Attached please find a check in the amount of **\$450.00** to cover the cost of the extension.

If any additional fees are due in connection with this paper, please charge our Deposit Account No. 50-2866.

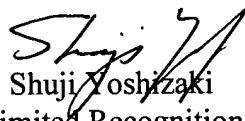
Respectfully submitted,

WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP

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Shuji Yoshizaki
Limited Recognition
Telephone: (202) 822-1100
Facsimile: (202) 822-1111

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